

**FOR INFORMATION ONLY:
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PARTS TO THIS DRAWING**

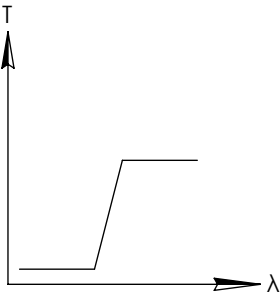
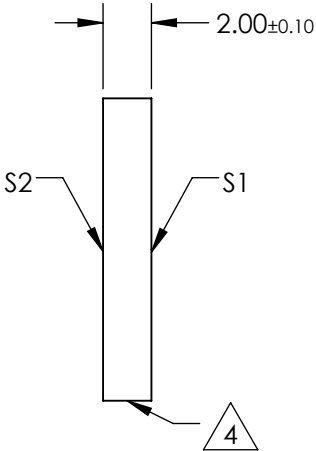
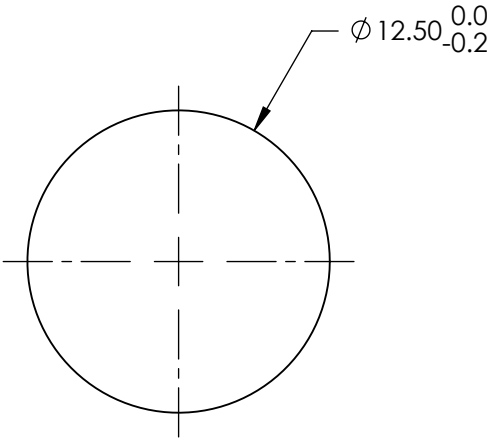
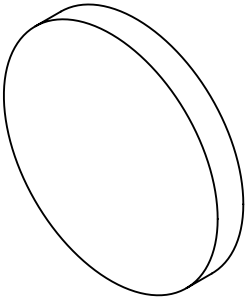
NOTES:

1. SUBSTRATE
2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): $\geq 91\%$ FROM 765 - 1650nm @ 0° AOI
T(avg): $\leq 0.01\%$ FROM 200 - 735nm @ 0° AOI
T(abs): $\approx 50\%$ FOR 750 \pm 7.5nm @ 0° AOI

S2: SINGLE LAYER MgF2

 FINE GRIND SURFACE

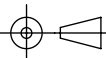
5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
6. TRANSMITTED WAVEFRONT DISTORTION, RMS: $\leq \lambda/4$ @ 633nm
7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION 		Edmund Optics®	
TITLE		Ø12.5mm, 750nm, HIGH PERFORMANCE LONGPASS FILTER	
ALL DIMS IN	mm	DWG NO	66226
			SHEET 1 OF 1

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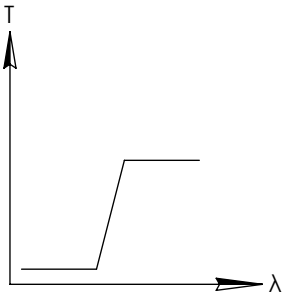
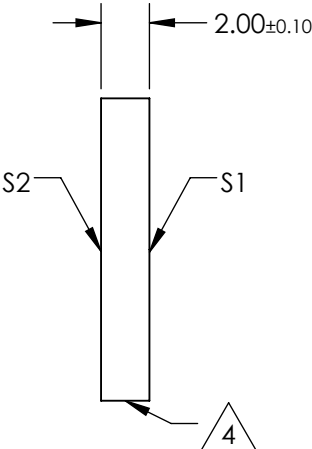
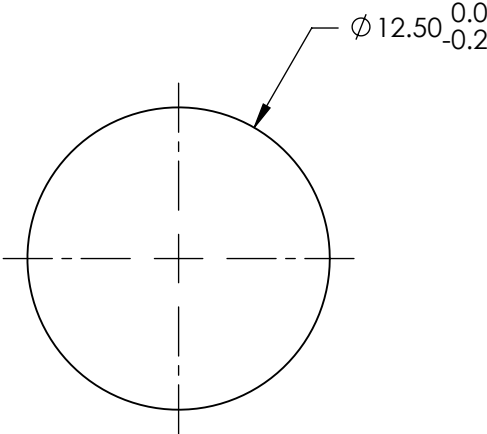
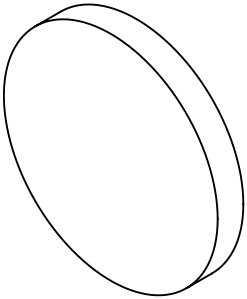
NOTES:

- SUBSTRATE
- SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
- COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): ≥91% FROM 815 - 1650nm @ 0° AOI
T(avg): ≤0.01% FROM 200 - 785nm @ 0° AOI
T(abs): =50% FOR 800±8nm @ 0° AOI

S2:SINGLE LAYER MgF2

4. FINE GRIND SURFACE

- POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
- TRANSMITTED WAVEFRONT DISTORTION, RMS: ≤λ/4 @ 633nm
- ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION		TITLE	Ø12.5mm, 800nm, HIGH PERFORMANCE LONGPASS FILTER
ALL DIMS IN	mm	DWG NO	66227
			SHEET 1 OF 1

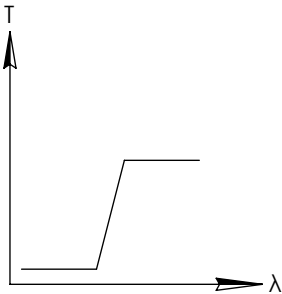
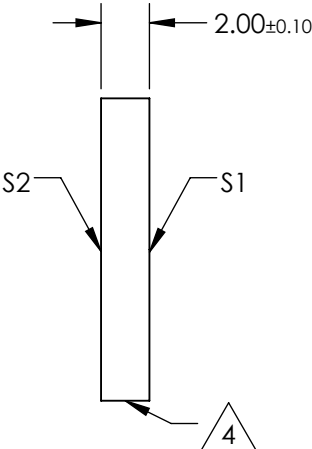
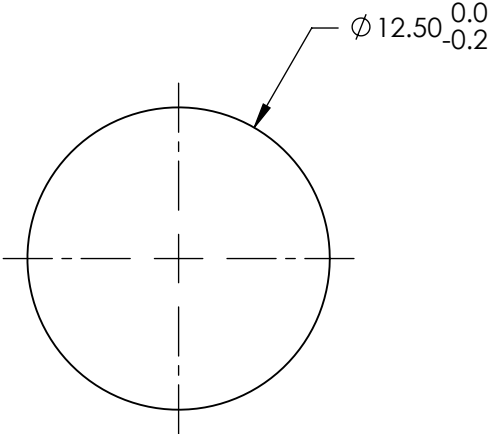
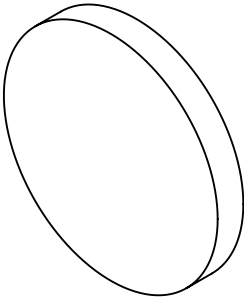
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NOTES:

- 1. SUBSTRATE
- 2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
- 3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): ≥91% FROM 865 - 1650nm @ 0° AOI
T(avg): ≤0.01% FROM 200 - 835nm @ 0° AOI
T(abs): =50% FOR 850±8.5nm @ 0° AOI
- S2:SINGLE LAYER MgF2

4. FINE GRIND SURFACE

- 5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
- 6. TRANSMITTED WAVEFRONT DISTORTION, RMS: ≤λ/4 @ 633nm
- 7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION		Edmund Optics®	
ALL DIMS IN mm		TITLE	Ø12.5mm, 850nm, HIGH PERFORMANCE LONGPASS FILTER
		DWG NO	66228
		SHEET 1 OF 1	

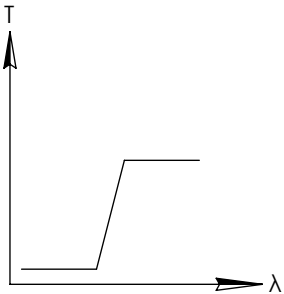
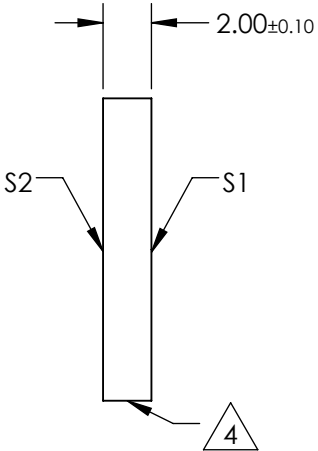
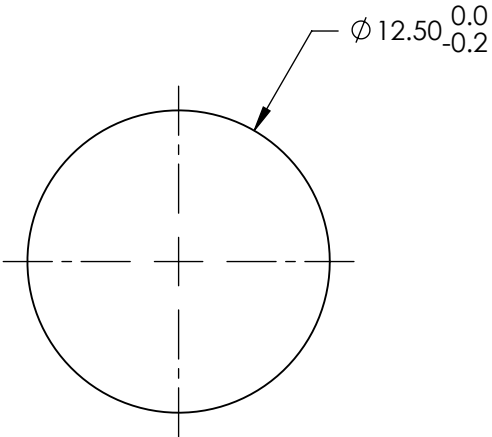
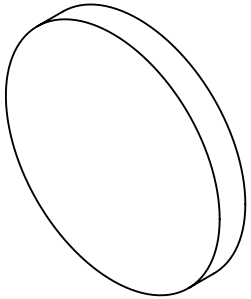
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NOTES:

1. SUBSTRATE
2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): $\geq 91\%$ FROM 915 - 1650nm @ 0° AOI
T(avg): $\leq 0.01\%$ FROM 200 - 880nm @ 0° AOI
T(abs): $\approx 50\%$ FOR 900 \pm 9nm @ 0° AOI
S2: SINGLE LAYER MgF2

 FINE GRIND SURFACE

5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
6. TRANSMITTED WAVEFRONT DISTORTION, RMS: $\leq \lambda/4$ @ 633nm
7. ROHS COMPLIANT




LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION	
ALL DIMS IN	mm

			
TITLE	Ø12.5mm, 900nm, HIGH PERFORMANCE LONGPASS FILTER		
DWG NO	66229	SHEET 1 OF 1	

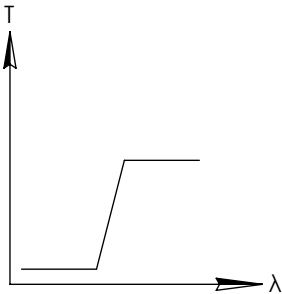
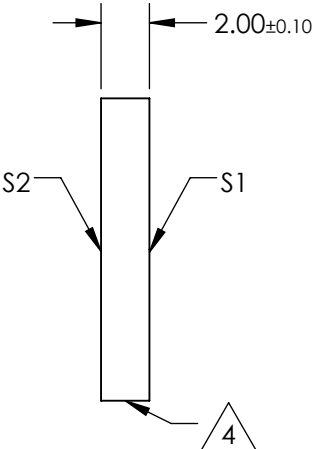
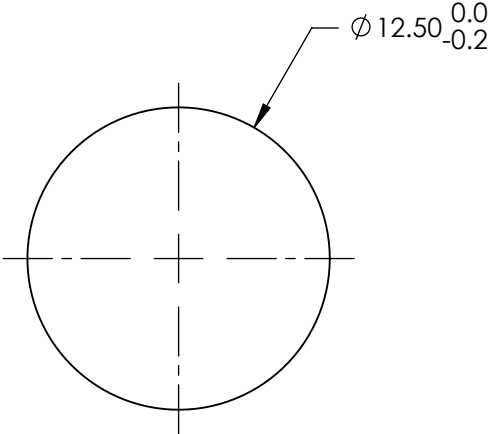
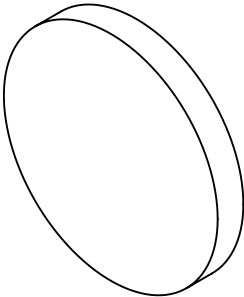
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NOTES:

- 1. SUBSTRATE
- 2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
- 3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): ≥91% FROM 965 - 1650nm @ 0° AOI
T(avg): ≤0.01% FROM 200 - 930nm @ 0° AOI
T(abs): =50% FOR 950±9.5nm @ 0° AOI
- S2:SINGLE LAYER MgF2

4. FINE GRIND SURFACE

- 5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
- 6. TRANSMITTED WAVEFRONT DISTORTION, RMS: ≤λ/4 @ 633nm
- 7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

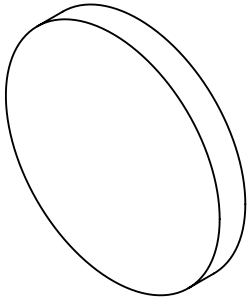
REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION		Edmund Optics®	
ALL DIMS IN mm		TITLE	Ø12.5mm, 950nm, HIGH PERFORMANCE LONGPASS FILTER
DWG NO		66230	SHEET 1 OF 1

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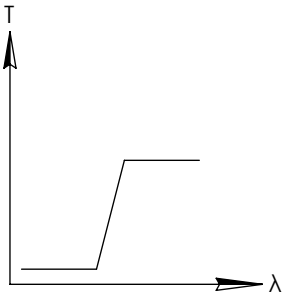
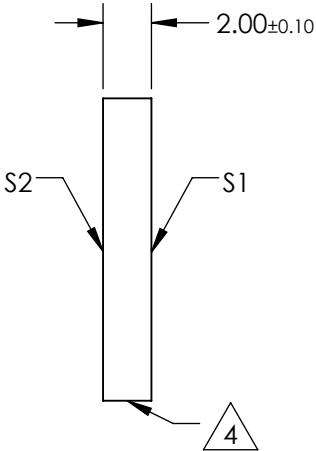
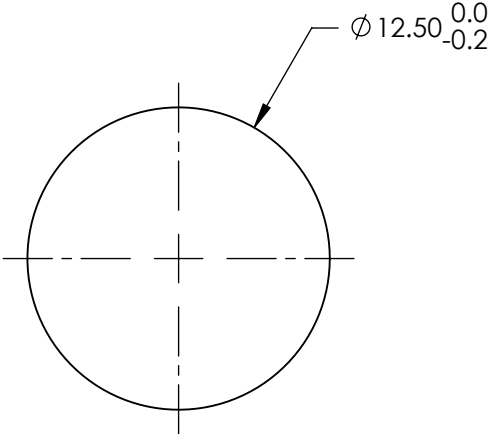
NOTES:

1. SUBSTRATE
2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): ≥91% FROM 1020 - 1650nm @ 0° AOI
T(avg): ≤0.01% FROM 200 - 980nm @ 0° AOI
T(abs): =50% FOR 1000±10nm @ 0° AOI



4. FINE GRIND SURFACE

5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
6. TRANSMITTED WAVEFRONT DISTORTION, RMS: ≤λ/4 @ 633nm
7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION		Edmund Optics®	
ALL DIMS IN mm		TITLE	Ø12.5mm, 1000nm, HIGH PERFORMANCE LONGPASS FILTER
DWG NO		66231	SHEET 1 OF 1

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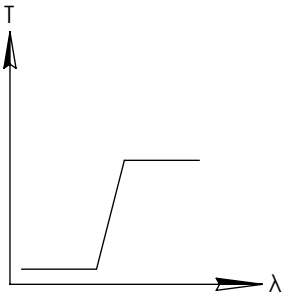
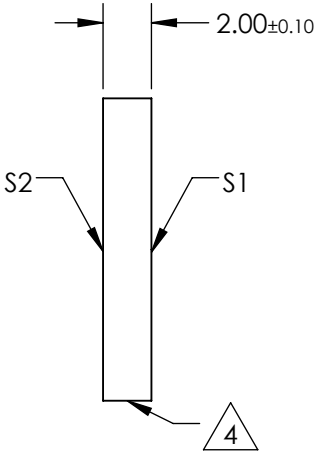
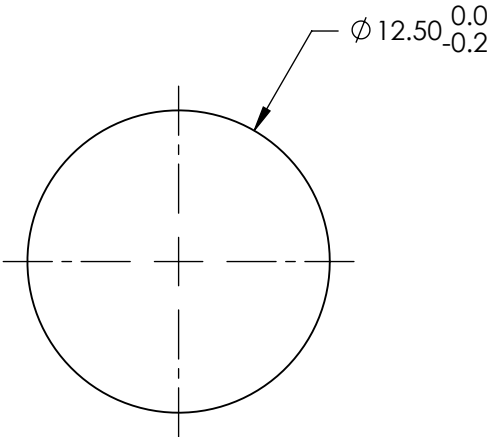
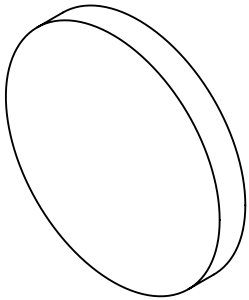
NOTES:

1. SUBSTRATE
2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): $\geq 91\%$ FROM 1070 - 1650nm @ 0° AOI
T(avg): $\leq 0.01\%$ FROM 200 - 1030nm @ 0° AOI
T(abs): =50% FOR 1050 \pm 10.5nm @ 0° AOI

S2:SINGLE LAYER MgF2

4. FINE GRIND SURFACE

5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
6. TRANSMITTED WAVEFRONT DISTORTION, RMS: $\leq \lambda/4$ @ 633nm
7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION		Edmund Optics®	
ALL DIMS IN mm		TITLE	Ø12.5mm, 1050nm, HIGH PERFORMANCE LONGPASS FILTER
DWG NO		66232	SHEET 1 OF 1

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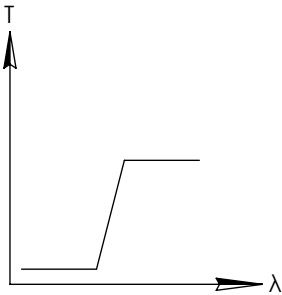
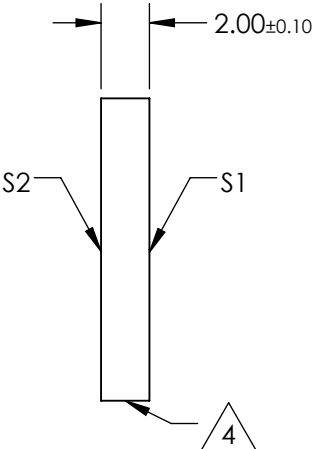
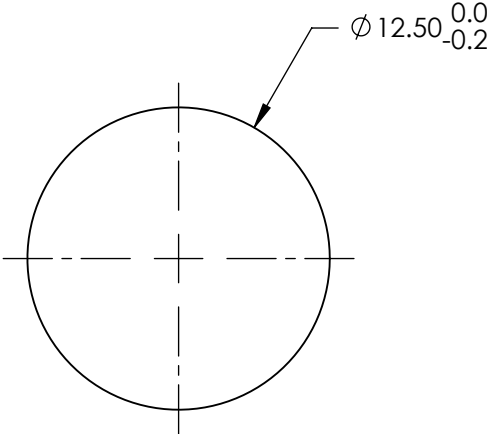
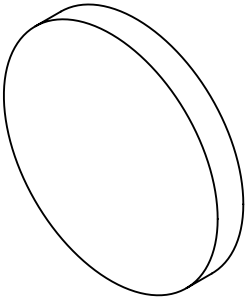
NOTES:

1. SUBSTRATE
2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): $\geq 91\%$ FROM 1120 - 1650nm @ 0° AOI
T(avg): $\leq 0.01\%$ FROM 200 - 1080nm @ 0° AOI
T(abs): $\approx 50\%$ FOR 1100 \pm 11nm @ 0° AOI

S2:SINGLE LAYER MgF2

 FINE GRIND SURFACE


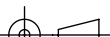
5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
6. TRANSMITTED WAVEFRONT DISTORTION, RMS: $\leq \lambda/4$ @ 633nm
7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

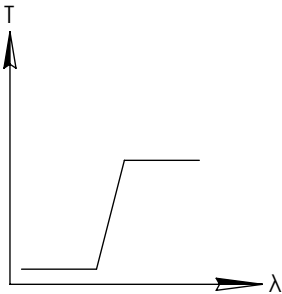
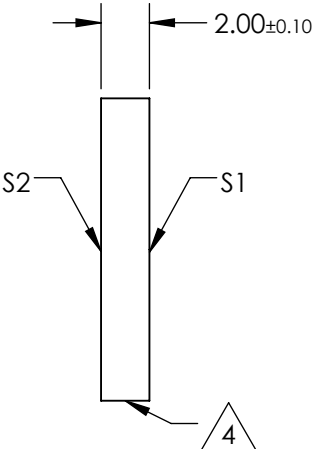
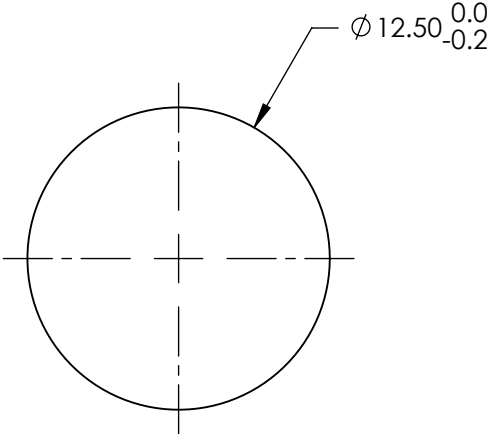
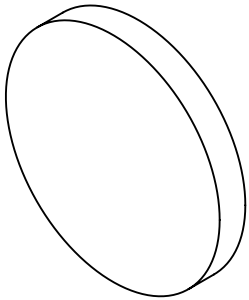
		 Edmund Optics®		
		TITLE	Ø12.5mm, 1100nm, HIGH PERFORMANCE LONGPASS FILTER	
ALL DIMS IN	mm	DWG NO	66233	SHEET 1 OF 1

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NOTES:

1. SUBSTRATE
2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): $\geq 91\%$ FROM 735 - 1650nm @ 0° AOI
T(avg): $\leq 0.01\%$ FROM 200 - 705nm @ 0° AOI
T(abs): $\approx 50\%$ FOR 725 \pm 7.25nm @ 0° AOI

S2:SINGLE LAYER MgF2
4. FINE GRIND SURFACE
5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
6. TRANSMITTED WAVEFRONT DISTORTION, RMS: $\leq \lambda/4$ @ 633nm
7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION		Edmund Optics®	
ALL DIMS IN mm		TITLE	Ø12.5mm, 725nm, HIGH PERFORMANCE LONGPASS FILTER
		DWG NO	86060
		SHEET 1 OF 1	

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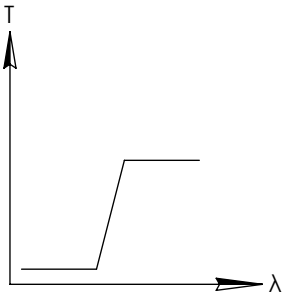
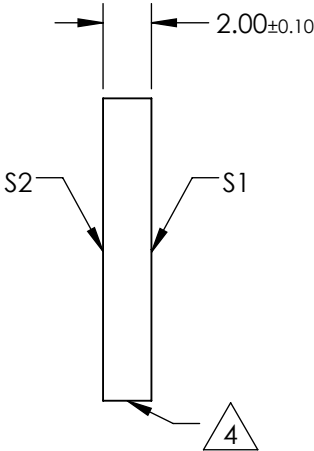
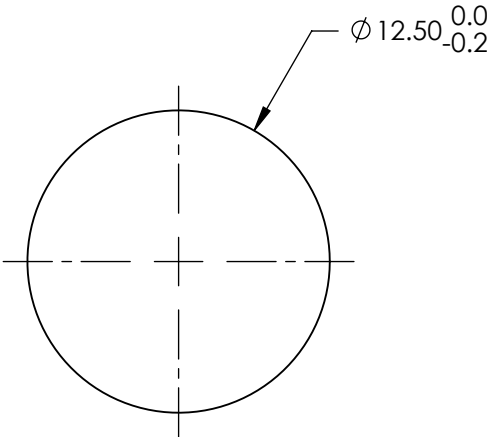
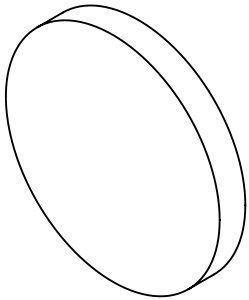
NOTES:

1. SUBSTRATE
2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): $\geq 91\%$ FROM 790 - 1650nm @ 0° AOI
T(avg): $\leq 0.01\%$ FROM 200 - 760nm @ 0° AOI
T(abs): $\approx 50\%$ FOR 775 \pm 7.75nm @ 0° AOI

S2: SINGLE LAYER MgF2

4. FINE GRIND SURFACE

5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
6. TRANSMITTED WAVEFRONT DISTORTION, RMS: $\leq \lambda/4$ @ 633nm
7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION		Edmund Optics®	
ALL DIMS IN mm		TITLE	Ø12.5mm, 775nm, HIGH PERFORMANCE LONGPASS FILTER
		DWG NO	86061
		SHEET 1 OF 1	

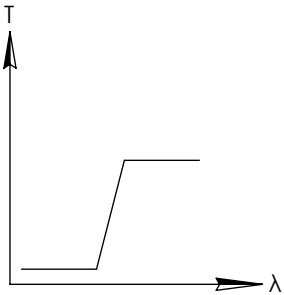
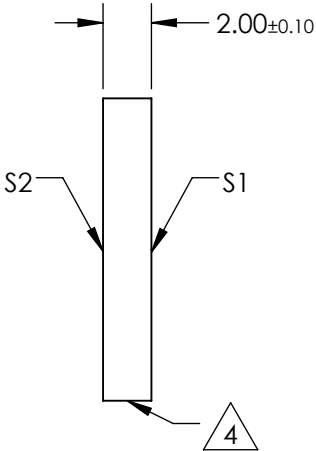
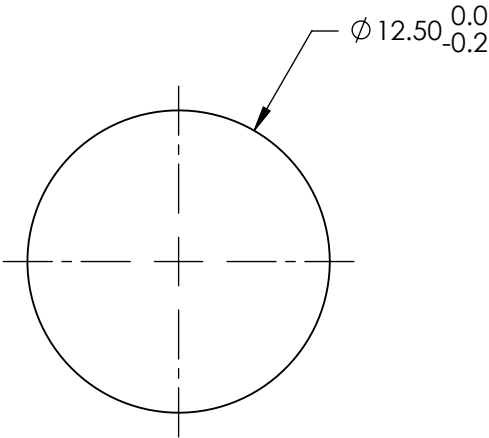
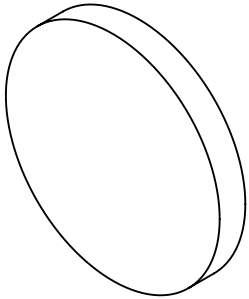
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NOTES:

1. SUBSTRATE
2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): $\geq 91\%$ FROM 840 - 1650nm @ 0° AOI
T(avg): $\leq 0.01\%$ FROM 200 - 805nm @ 0° AOI
T(abs): $\approx 50\%$ FOR 825 \pm 8.25nm @ 0° AOI
S2: SINGLE LAYER MgF2

4. FINE GRIND SURFACE

5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
6. TRANSMITTED WAVEFRONT DISTORTION, RMS: $\leq \lambda/4$ @ 633nm
7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION		TITLE		Ø12.5mm, 825nm, HIGH PERFORMANCE LONGPASS FILTER	
ALL DIMS IN	mm	DWG NO	86062	SHEET 1 OF 1	

Edmund Optics®

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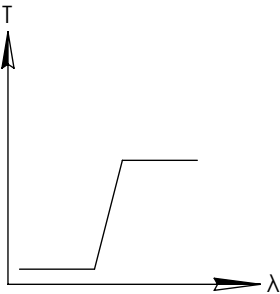
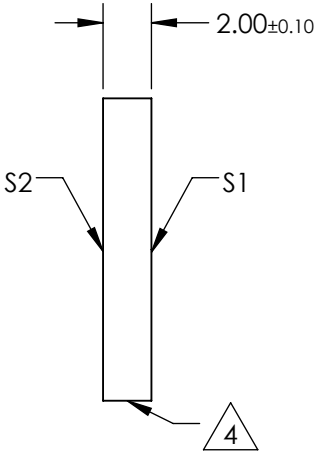
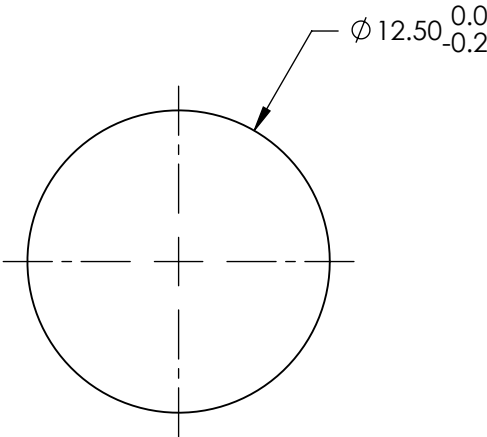
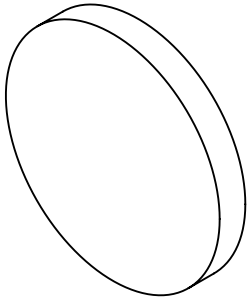
NOTES:

1. SUBSTRATE
2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): ≥91% FROM 890 - 1650nm @ 0° AOI
T(avg): ≤0.01% FROM 200 - 860nm @ 0° AOI
T(abs): =50% FOR 875±8.75nm @ 0° AOI

S2:SINGLE LAYER MgF2

4. FINE GRIND SURFACE

5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
6. TRANSMITTED WAVEFRONT DISTORTION, RMS: ≤λ/4 @ 633nm
7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION		Edmund Optics®	
TITLE		Ø12.5mm, 875nm, HIGH PERFORMANCE LONGPASS FILTER	
ALL DIMS IN	mm	DWG NO	86063
			SHEET 1 OF 1

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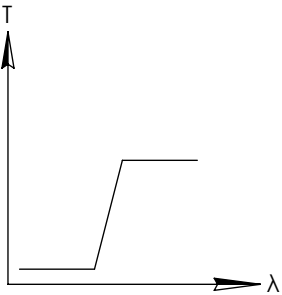
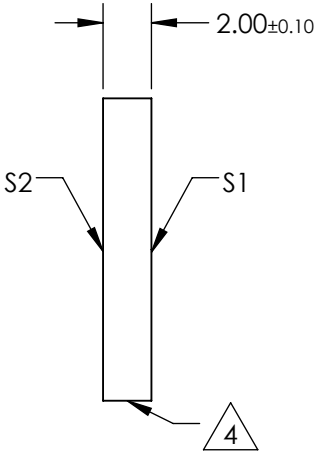
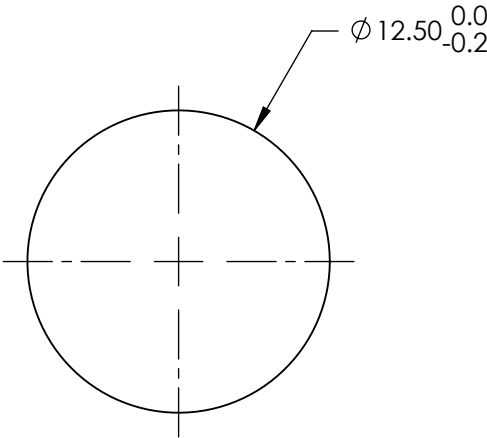
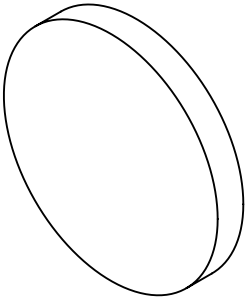
NOTES:

1. SUBSTRATE
2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): $\geq 91\%$ FROM 940 - 1650nm @ 0° AOI
T(avg): $\leq 0.01\%$ FROM 200 - 905nm @ 0° AOI
T(abs): $\approx 50\%$ FOR 925 \pm 9.25nm @ 0° AOI

S2: SINGLE LAYER MgF2

 FINE GRIND SURFACE

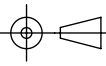

5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
6. TRANSMITTED WAVEFRONT DISTORTION, RMS: $\leq \lambda/4$ @ 633nm
7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION 		 Edmund Optics®	
TITLE		Ø12.5mm, 925nm, HIGH PERFORMANCE LONGPASS FILTER	
ALL DIMS IN	mm	DWG NO	86064
			SHEET 1 OF 1

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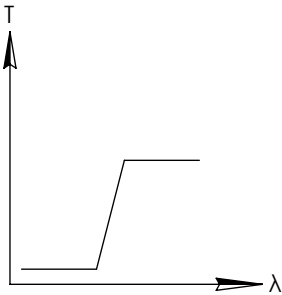
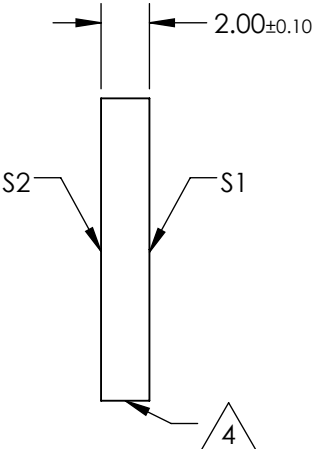
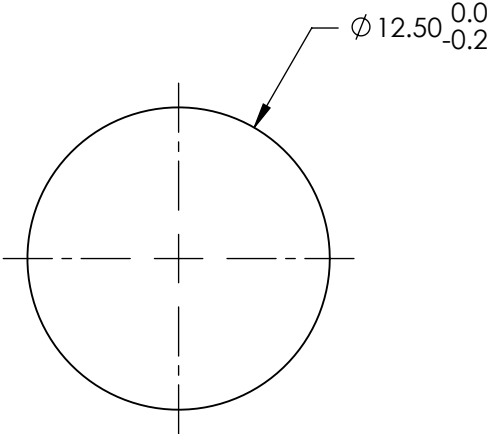
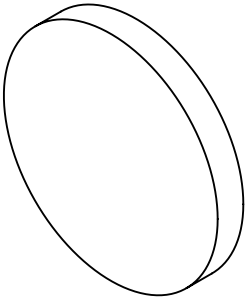
NOTES:

1. SUBSTRATE
2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): ≥91% FROM 990 - 1650nm @ 0° AOI
T(avg): ≤0.01% FROM 200 - 955nm @ 0° AOI
T(abs): =50% FOR 975±9.75nm @ 0° AOI

S2:SINGLE LAYER MgF2

4. FINE GRIND SURFACE

5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
6. TRANSMITTED WAVEFRONT DISTORTION, RMS: ≤λ/4 @ 633nm
7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE PROJECTION					
ALL DIMS IN		mm		TITLE	Ø12.5mm, 975nm, HIGH PERFORMANCE LONGPASS FILTER
		DWG NO		86065	SHEET 1 OF 1

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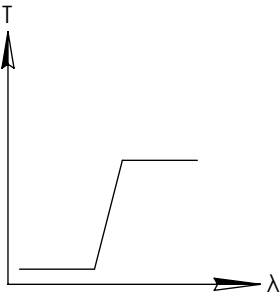
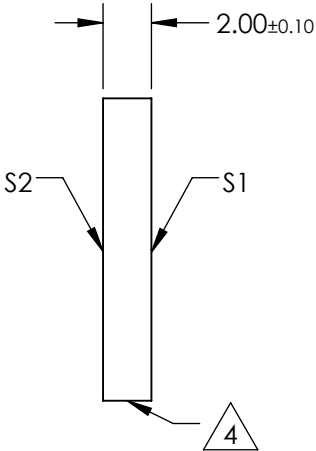
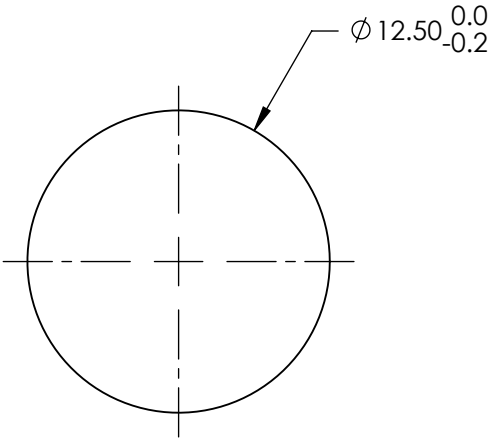
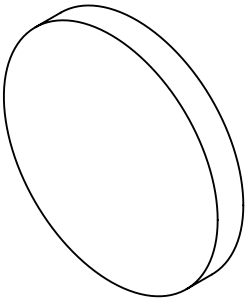
NOTES:

1. SUBSTRATE
2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
3. COATING (APPLY ACROSS COATING APERTURE)
S1: HARD DIELECTRIC SPUTTERED
T(avg): $\geq 91\%$ FROM 1045 - 1650nm @ 0° AOI
T(avg): $\leq 0.01\%$ FROM 200 - 1005nm @ 0° AOI
T(abs): $\approx 50\%$ FOR 1025 \pm 10.25nm @ 0° AOI

S2:SINGLE LAYER MgF2

 FINE GRIND SURFACE


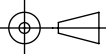
5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
6. TRANSMITTED WAVEFRONT DISTORTION, RMS: $\leq \lambda/4$ @ 633nm
7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

			
THIRD ANGLE PROJECTION 		TITLE	Ø12.5mm, 1025nm, HIGH PERFORMANCE LONGPASS FILTER
ALL DIMS IN	mm	DWG NO	86066
			SHEET 1 OF 1

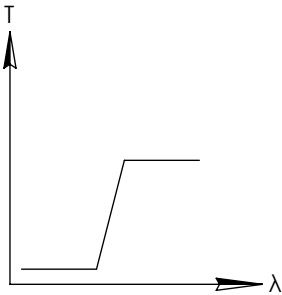
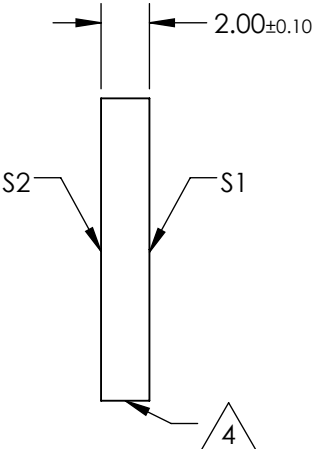
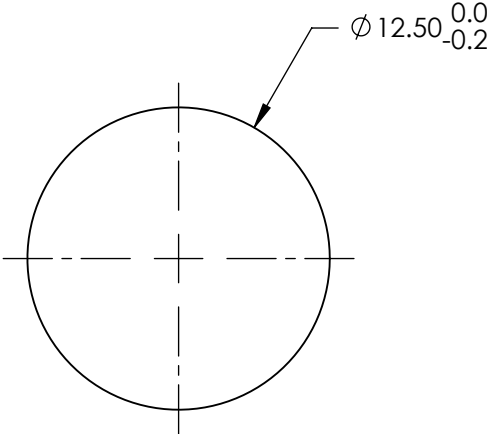
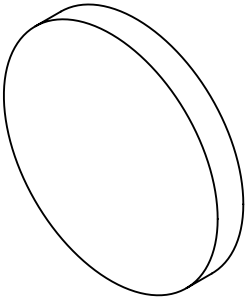
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NOTES:

- 1. SUBSTRATE
- 2. SURFACE S2 TO BE PARALLEL WITH SURFACE S1 TO WITHIN 5 arcsec
- 3. COATING (APPLY ACROSS COATING APERTURE)
 - S1: HARD DIELECTRIC SPUTTERED
 - T(avg): ≥91% FROM 1095 - 1650nm @ 0° AOI
 - T(avg): ≤0.01% FROM 200 - 1055nm @ 0° AOI
 - T(abs): =50% FOR 1075±10.75nm @ 0° AOI
 - S2:SINGLE LAYER MgF2

4. FINE GRIND SURFACE

- 5. POWER, IRREGULARITY, AND SURFACE QUALITY SPECIFICATIONS
APPLY ACROSS CLEAR APERTURE
- 6. TRANSMITTED WAVEFRONT DISTORTION, RMS: ≤λ/4 @ 633nm
- 7. ROHS COMPLIANT



LONGPASS FILTER

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE
DIMENSIONS ARE FOR REFERENCE ONLY

REV A	S1	S2
SHAPE	PLANO	PLANO
SURFACE QUALITY	40-20	40-20
CLEAR APERTURE	>80%	>80%
BEVEL	PROTECTIVE AS NEEDED	PROTECTIVE AS NEEDED

THIRD ANGLE
PROJECTION

ALL DIMS IN

mm

TITLE

Ø12.5mm, 1075nm, HIGH PERFORMANCE
LONGPASS FILTER

DWG NO

86067

SHEET
1 OF 1

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